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FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO. MICRON.095C1

APPLICATION NO.

10/687,086

INFORMATION DISCLOSURE STATEMENT
BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)

APPLICANT Agarwal, et al.

FILING DATE Herewith

GROUP Unknown

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*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.

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| FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE STATEMENT BY APPLICANT (USE SEVERAL SHEETS IF NECESSARY) | | | | ATTY. DOCKET NO. MICRON.095C1 | APPLICATION NO. Unkgown 10 687086 | | | | | |
| | | | APPLICANT Agarwal, et al. | | | | | | | |
| | | | | FILING DATE Herewith | GROUP Unknown | | | | | |
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| INITIAL | | | | | | | | YES | NO | |
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